

Figure 1

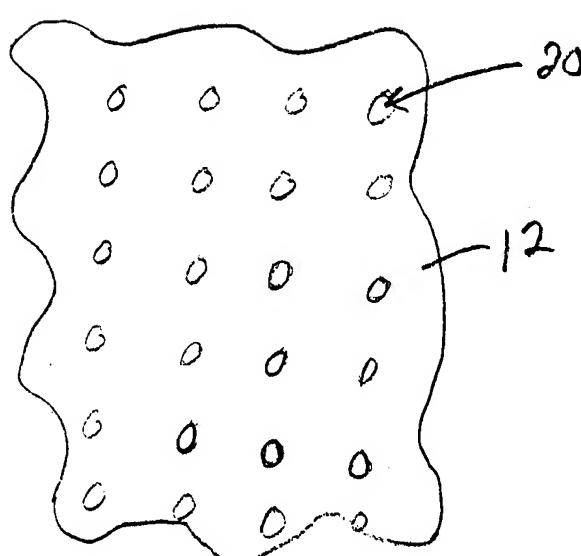


Figure 2

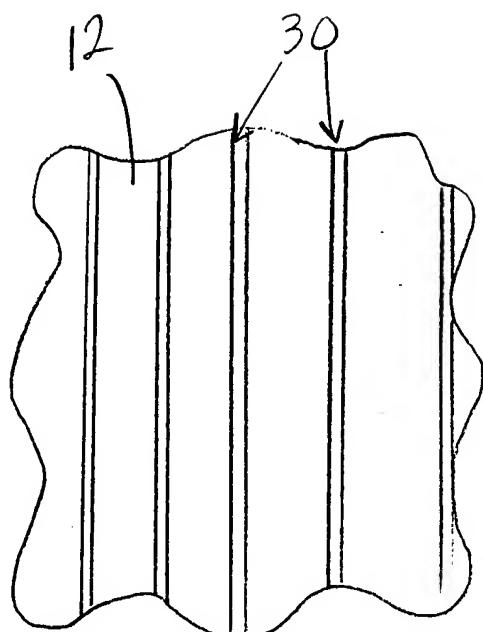


Figure 3

Position the shield around the semiconductor wafer.

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Rotate the wafer/substrate.

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Apply the cleaning fluid.

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Collection of cleaning fluid by and/or drains down the semi-permeable material.

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Figure 4